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|-----------------------------------|--|-------------------------|---|-------------|
| Notice of References Cited | | Application/Control No. | Applicant(s)/Patent Under Reexamination | |
| | | 09/749,585 | HEITKAMP, ROSS SUYDAM | |
| Examiner | | Art Unit | | Page 1 of 1 |
| Kim T. Huynh | | 2112 | | |

U.S. PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Name | Classification |
|---|---|--|-----------------|---------------------|----------------|
| | A | US-2004/0098525 A1 | 05-2004 | Wang et al. | 710/110 |
| | B | US-5,553,248 A | 09-1996 | Melo et al. | 710/116 |
| | C | US-6,622,191 B1 | 09-2003 | Nakamura, Nobutaka | 710/260 |
| | D | US-2003/0115393 A1 | 06-2003 | Kim, Jin-soo | 710/240 |
| | E | US-6,496,890 B1 | 12-2002 | Azevedo et al. | 710/110 |
| | F | US-6,662,306 B2 | 12-2003 | Van Loo, William C. | 713/600 |
| | G | US-6,189,061 B1 | 02-2001 | Katz et al. | 710/110 |
| | H | US- | | | |
| | I | US- | | | |
| | J | US- | | | |
| | K | US- | | | |
| | L | US- | | | |
| | M | US- | | | |

FOREIGN PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Country | Name | Classification |
|---|---|--|-----------------|---------|------|----------------|
| | N | | | | | |
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| | P | | | | | |
| | Q | | | | | |
| | R | | | | | |
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NON-PATENT DOCUMENTS

| | | |
|---|---|---|
| * | | Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages) |
| | U | |
| | V | |
| | W | |
| | X | |

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